

INFORMATION DISCLOSURE CITATION IN AN APPLICATION (PTO-1449)				ATTY. DOCKET NO. 50432-614	SERIAL NO.		
				APPLICANT Darrell M. ERB, et al.			
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U.S. PATENT DOCUMENTS							
EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Code ₂ (<i>if known</i>)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document		Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	
BS		US 6,207,552 B1	03/27/2001	Wang et al.			
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FOREIGN PATENT DOCUMENTS							
EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Code ₃ -Number «-Kind Codes (<i>if known</i>)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Figures Appear	Translation	
						Yes	No
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.					
BS		E. T. OGAWA, et al., "Stress-Induced Voiding Under Vias Connected to Wide Cu Metal Leads", April 2002, p. 312-321					
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BS		D. EDELSTEIN, et al., "An Optical Liner for Copper Damascene Interconnects", Conference Proceedings ULSI XVII, 2002, p. 541-547					
EXAMINER <i>Ben Sandvik</i>			DATE CONSIDERED <i>4/12/05</i>				

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